## **EAST Search History**

	LAST Search History									
Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp				
L5	4538	switch\$3 with gas with liquid	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/17 12:03				
L11	57250	retaining adj ring	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/17 12:10				
L12	2	I11 and I5 and (wafer semiconductor substrate)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/17 12:10				
L13	669	I11 and (moist\$4 with (air gas))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/17 12:10				
L15	144	l13 and (wafer substrate semiconductor)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/17 12:13				
L16	18	I13 and (cmp (chemical adj mechanical adj polish\$4))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/17 12:15				
L17	215	(moist\$4 adj (gas air)) and (cmp (chemical adj mechanical adj polish\$4))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/17 12:15				

3/17/07 12:35:21 PM

## **EAST Search History**

S22	9951	(slot opening hole) with (retaining adj ring)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/15 13:56
S23	623	S22 and (wafer substrate semiconductor)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/15 13:56
S24	376	S23 and (fluid gas)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/15 13:56
S25	89	S24 and cleaning	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/15 13:57
S26	3484673	wafer substrate semiconductor	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/16 11:28
S27	2499720	holder carrier	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/03/16 11:28